

## Nonlinear I-V characteristics in $\alpha$ -(BEDT-TTF)<sub>2</sub>I<sub>3</sub>

Kota Kodama<sup>1,2</sup>, Takahide Yamaguchi<sup>1</sup>, Taichi Terashima<sup>1</sup>, Motoi Kimata<sup>1</sup>, Hidetaka Satsukawa<sup>1</sup>, Atsushi Harada<sup>1</sup>, Kaori Hazama<sup>1,2</sup>, Shinya Uji<sup>1,2</sup>, Kaoru Yamamoto<sup>3</sup>, and Kyuya Yakushi<sup>3</sup>

<sup>1</sup>National Institute for Materials Science, Ibaraki, Japan

<sup>2</sup>Graduate School of Pure and Applied Science, University of Tsukuba, Ibaraki, Japan

<sup>3</sup>Institute for Molecular Science, Okazaki, Japan

Email: Kodama.kouta@nims.go.jp

A two-dimensional (2D) organic conductor  $\alpha$ -(BEDT-TTF)<sub>2</sub>I<sub>3</sub> is well known as a charge ordered (CO) system. In a few two dimensional CO systems, strong non-linear I-V characteristics (power law behavior  $I \sim V^\alpha$ ) have been observed in high voltage regions.[1] In order to investigate the universal I-V behavior in 2D CO systems, we have measured I-V characteristics at various temperatures in a wide electric field region for  $\alpha$ -(BEDT-TTF)<sub>2</sub>I<sub>3</sub>. The temperature dependence of the inplane resistance in  $\alpha$ -(BEDT-TTF)<sub>2</sub>I<sub>3</sub> shows thermal activation type  $\sigma = \sigma_0 \exp(-\Delta/2k_B T)$  with  $\Delta = 660$  K below 70 K for low bias voltage (in linear I-V region). The carriers are expected to be thermally excited electron-hole pairs. When the electrical flux between the excited hole and electron is well confined in the 2D layer, the Coulomb potential between them is approximately given by  $U_0 \ln(r/a)$ , where  $r$  is the electron-hole distance, and  $a$  is the minimum length, which should be comparable to the size of BEDT-TTF molecule. In a large  $r$  region, we assume constant potential  $U_0 \ln(\lambda/a)$  for  $r > \lambda$ , where  $\lambda$  is the cut-off length. The factor  $U_0$  depends on the dielectric constants of the BEDT-TTF and I<sub>3</sub> layers. Since the maximum Coulomb potential between the excited electron and hole is written as  $\Delta(E) = U_0 [\ln(U_0/aeE) - 1]$  for high electric field  $E$ , we get the power law  $I \sim E^\alpha$  and  $\alpha = U_0/2k_B T + 1$  whereas  $\alpha = 1$  for low  $E$ . Figure 1 shows the experimental results and the simulations. We see power law behavior in the high  $V$  region at low temperatures. The simulations are made for  $U_0/2k_B = 165$  K,  $a = 0.5$  nm,  $\lambda = 120$  nm and the voltage contact spacing  $d = 40$   $\mu$ m. The experimental results are well reproduced except for  $T = 15$  and 20 K. It may be due to quantum tunneling effect. The magnetic field effect on the nonlinear I-V characteristics will be also presented.

[1] Y. Takahide *et al.*, Phys. Rev. Lett. **96** (2006) 136602

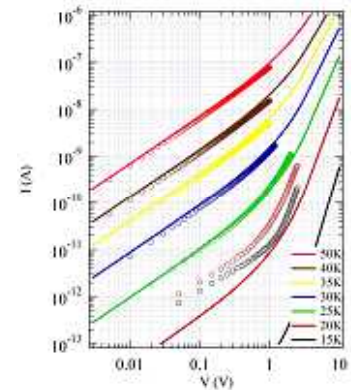


Fig. 1. Experimental results (circles) and simulations (solid curves) of I-V characteristics.